Docket No.:

005916 USA/FPS/MMCS/MC

PATENT/OFFICIAL

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

e Application of

Young Joseph PAIK

Serial No. 09/998,384

Group Art Unit: 2812

Filed: November 30, 2001

Examiner:

For:

FEEDFORWARD AND FEEDBACK CONTROL FOR CONDITIONING OF

CHEMICAL MECHANICAL POLISHING PAD

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

Honorable Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In accordance with the provisions of 37 C.F.R. 1.56, 1.97 and 1.98, the attention of the Patent and Trademark Office is hereby directed to the documents listed on the attached form PTO-1449. It is respectfully requested that the documents be expressly considered during the prosecution of this application, and that the documents be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

This Information Disclosure Statement is being filed within three months of the U.S. filing date OR before the mailing date of a first Office Action on the merits. No certification or fee is required.

This submission does not constitute a representation that a search has been made or that no better art exists and does not constitute an admission or representation that any of the listed documents is material or constitutes prior art. If it should be determined that any of the listed documents does not constitute prior art under the United States law, Applicants reserve the right Serial No. 09/998,384

to present to the Office the relevant facts and law regarding the appropriate status of such

document.

The references listed on Sheet 1 of the attached PTO-1449 Forms were cited in a

patentability investigation and/or a corresponding foreign or PCT application relating to the

above-referenced application. The remaining references are from potentially related patent

applications, and possibly other sources.

No certification or fee is believed to be required. However, the Commissioner is hereby

authorized to charge any additional fees should any be required for this submission, or credit any

overpayment to deposit account no. 08-0219.

Respectfully submitted,

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Date:

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